

Supplementary Information

Photostriction in CaTiO_3 ceramics under the illumination of light emitting diode

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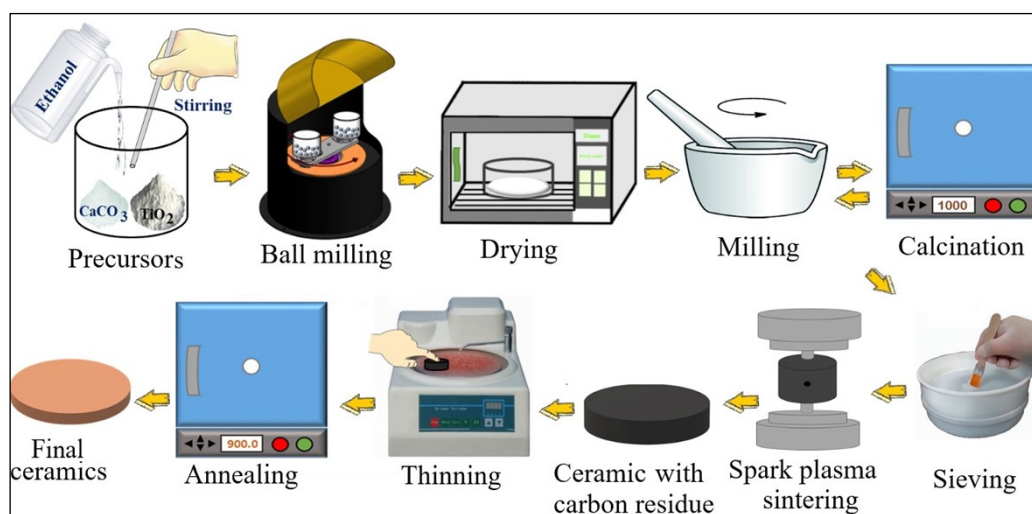


Fig. S1 Schematic representation of the routemap followed in the synthesis of CaTiO_3 ceramics.

Photostriction measurement: Based on the research work of B. Kundy's et al [1], the home made setup, as schematically shown in Fig. S1, was used for the photostriction measurement. At first, the CaTiO_3 ceramic sample with dimensions $2 \times 7 \times 0.3 \text{ mm}^3$ was placed at the sample stage and then the suspended part of the sample was irradiated. The photoinduced elongation in the sample pushes the sensitive electrode and thereby changes the separation between the sensitive and base electrode. The corresponding change in the capacitance is measured by an automatic component analyser (TH2838 Automatic Component Analyzer, Tonghui, China). The photostriction $\lambda = \Delta L/L$ is calculated by using the following equations;

$$\lambda = \Delta L/L = (L_2 - L_1)/L$$

$$L_1 = 254.3 - 515.9 \times e^{-C_1/38.6} - 124.3 \times e^{-C_1/38.59} - 158.6 \times e^{-C_1/583.58}$$

$$L_2 = 254.3 - 515.9 \times e^{-C_2/38.6} - 124.3 \times e^{-C_2/38.59} - 158.6 \times e^{-C_2/583.58}$$

where C_1 is the capacitance value before illumination, C_2 is the capacitance value under illumination, L is the length of the sample subjected to laser irradiation (which turns out to be 4 mm under LED's 365 and 405 nm, and 3.2 mm under laser light 405 nm).

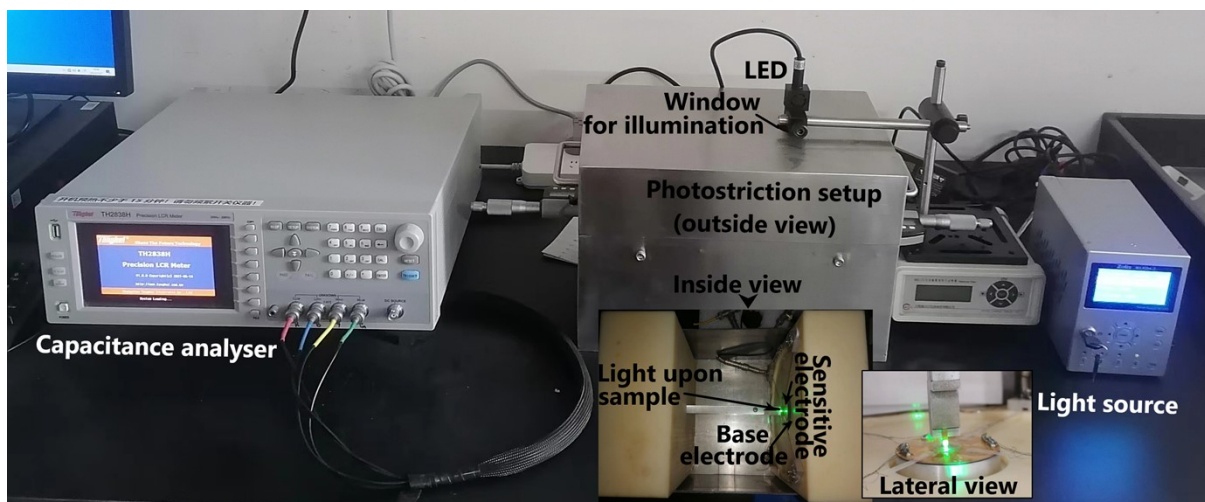


Fig. S2 Schematic representation of photostriction measuring setup.

Table S1. Comparison of the photostrictive parameters of CaTiO₃ ceramics with that of the reported materials.

Material	Light		Photostriction	
	Wavelength (nm)	Intensity/fluence	Response $\Delta L/L$ (%)	Efficiency (m ³ /W)
PLZT ceramics ²	365	150 W/m ²	0.01	3.3*10 ⁻¹⁰
BiFeO ₃ crystal ¹	365	326 W/m ²	0.003	8.2*10 ⁻¹²
CH ₃ NH ₃ PbBr ₃ crystal ³	532	60 W/cm ²	- 1.25	- 5.6*10 ⁻¹¹
PbTiO ₃ film ⁴	400	4.8 mJ/cm ²	0.25	5.2*10 ⁻²⁶
BiFeO ₃ film ⁵	400	2 mJ/cm ²	0.46	4*10 ⁻²⁵
BaTiO ₃ crystal ⁶	405	4.8 mJ cm ⁻²	0.25	5.2*10 ⁻²⁶
BNNPT ceramic ⁷	520	67.6	0.38	1.1*10 ⁻¹¹
MAPbI ₃ film ⁸	532	1 kW/m ²	0.125	5.0*10 ⁻¹²
SrRuO ₃ film ⁹	532	625 kW/m ²	1.12	7.0*10 ⁻¹⁶
Te film ¹⁰	633	34	0.01	2.6*10 ⁻¹⁶
CaFe ₂ O ₄ ceramic ¹¹	405	25	0.13	1.3*10 ⁻¹¹
	520	25	0.11	1.1*10 ⁻¹¹
	655	25	0.16	1.0*10 ⁻¹¹
CaCuTi ₄ O ₁₂ ceramics ¹²	520	67.6 kW/m ²	0.31	9.2*10 ⁻¹²
	655	41.2 kW/m ²	0.17	8.3*10 ⁻¹²
Zn ₃ V ₂ O ₈ ceramics ¹³	405	18 kW/m ²	0.08	8.8*10 ⁻¹²
	655	18 kW/m ²	0.05	5.5*10 ⁻¹²
Mg ₃ V ₂ O ₈ Ceramics ¹⁴	405	3 kW/m ²	0.015	1.0*10 ⁻¹¹
	520	20 kW/m ²	0.09	9.0*10 ⁻¹²
	655	3 kW/m ²	0.024	1.5*10 ⁻¹¹
CaTiO₃	LED-365	2 kW/m ²	0.015	0.22 × 10 ⁻¹⁰
ceramics	LED-405	2 kW/m ²	0.012	0.19 × 10 ⁻¹⁰

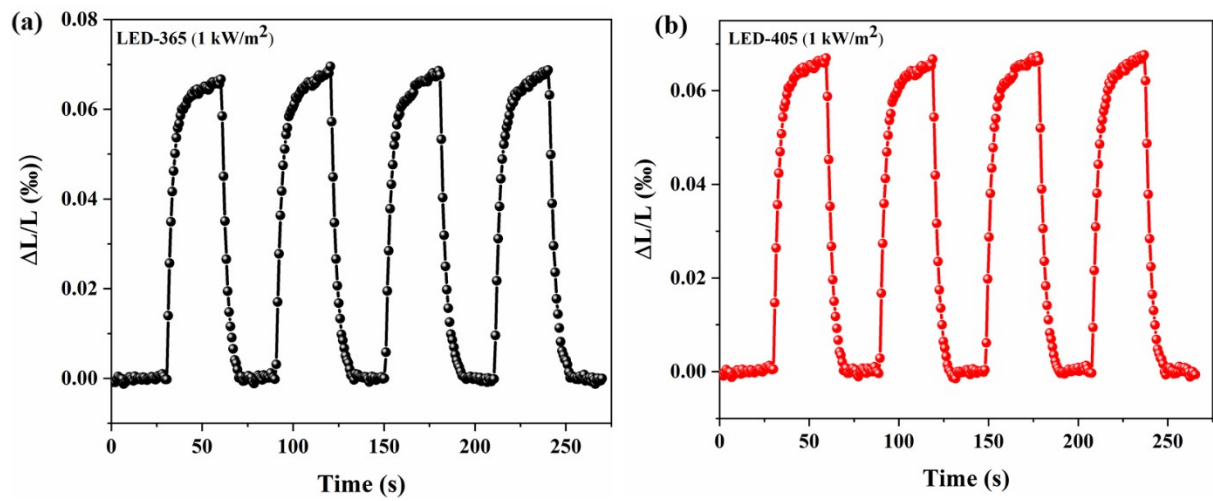


Fig. S3 Reproducibility of photostriction $\Delta L/L$ of CaTiO_3 ceramic sample at 1 sun illumination under; (a) LED 365 nm, and (b) 405 nm.

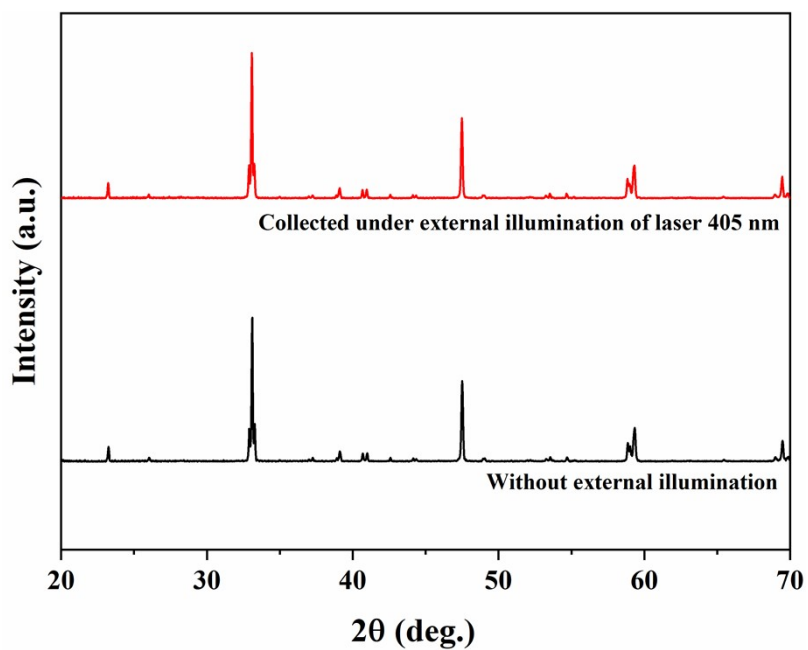


Fig. S4. X-ray diffraction patterns of CaTiO₃ ceramic collected with and without external laser illumination.

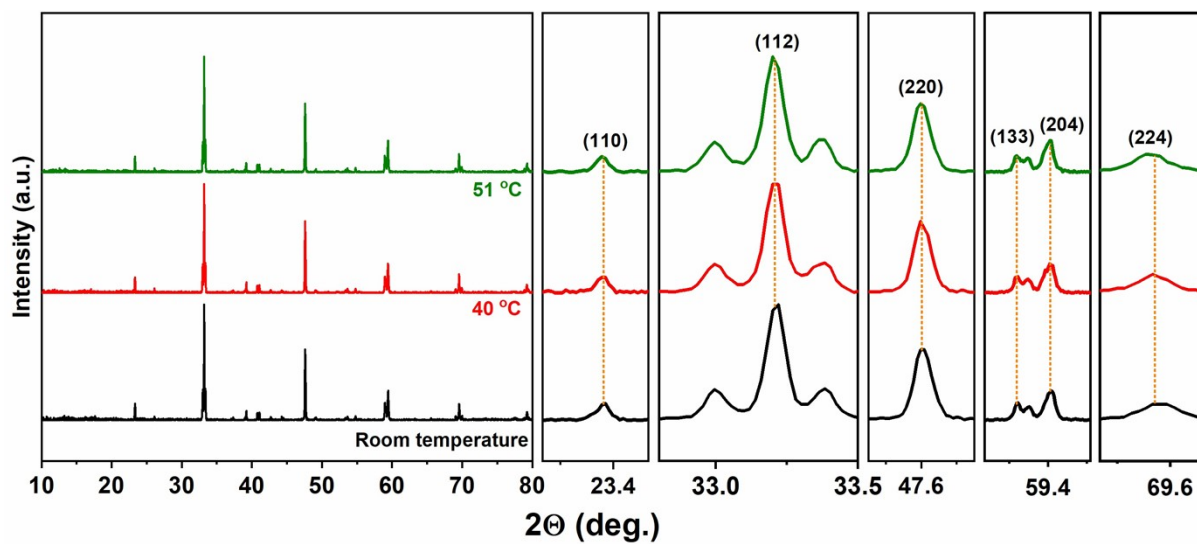


Fig. S5 Temperature dependent X-ray diffraction patterns of CaTiO₃ ceramics.

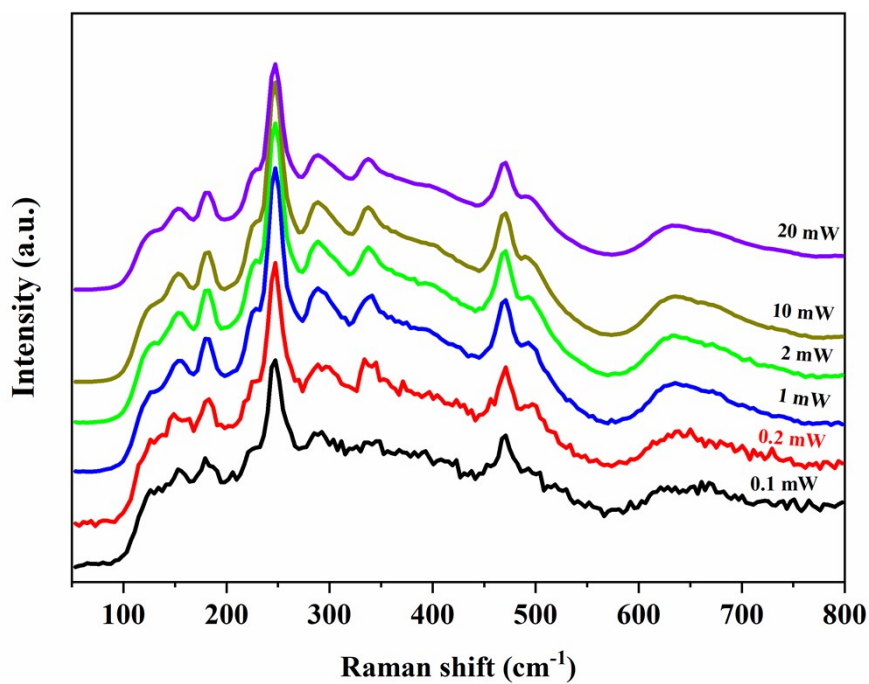


Fig. S6 Raman spectra's of CaTiO₃ ceramics at various laser (473 nm) powers.

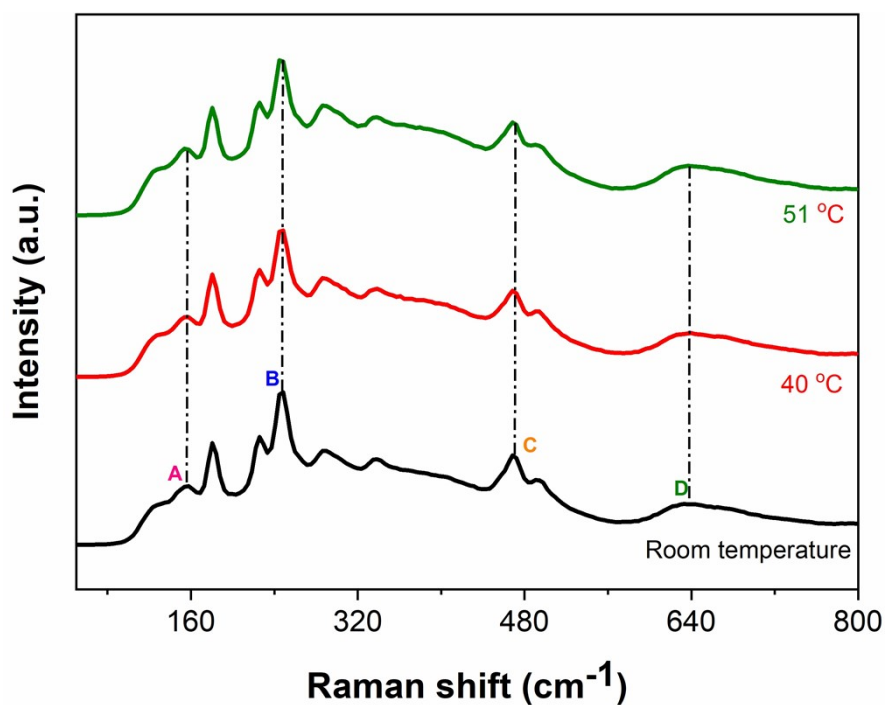


Fig. S7 Temperature dependent Raman spectra's of CaTiO₃ ceramics recorded while excitation wavelength 473 nm (at power of 20 mW).

References

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